Bending Magnet & Insertion Devices **Bending Magnet &
Insertion Devices
Hamed Tarawneh
ICTP School on Synchrotron Light Sources and their Applications, Jan. 2023**

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**ending Magnet & Insertion Dev
Outline:
• Synchrotron radiation (SR) sources.
• SR Characterstics ng Magnet & Insert

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hrotron radiation (SR) sources.

haracterstics

Photon Energy

Flux & Brilliance

Coherence

Polarization Bending Magnet & Insertion Devices

Outline:

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- SR Characterstics
	- Flux & Brilliance Coherence Polarization
-
- ID Performance.
- **Outline:**
• Synchrotron radiation (SR) sources.
• SR Characterstics
• Flux & Brilliance
• Coherence
• Insertion Devices (ID) Technologies.
• ID Performance.
• Magnetic Measurements Techniques. • Synchrotron radiation (SR) sources.
• SR Characterstics
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• Insertion Devices (ID) Technologies.
• ID Performance.
• Magnetic Measurements Techniques.
• ID's Effect on Electr • Synchrotron radiation (SR) sources.
• SR Characterstics
• Photon Energy
• Flux & Brilliance
• Coherence
• Polarization
• Insertion Devices (ID) Technologies.
• ID Performance.
• Magnetic Measurements Techniques.
• ID's E
-
- Summary.
- Bibliography.

¹ MAX IV Facility

3 GeV ring

Short Pulse Facility

 -21

 \mathbb{P}_α

GeV Linac

.5 GeV ring

Synchrotron Radiation Sources

- **Synchrotron Radiation Sources**
• Synchrotron Radiation is an electromagnetic radiation emitted when charged
particles, Electrons, travel in a curved path. The electrons are moving under the
influence of an electromagnetic **Synchrotron Radiation Sources**
Synchrotron Radiation is an electromagnetic radiation emitted when charged
particles, Electrons, travel in a curved path. The electrons are moving under the
influence of an electromagnetic f **Synchrotron Radiation Source Synchrotron Radiation is an electromagnetic radiation emitted wheraticles, Electrons, travel in a curved path. The electrons are moving influence of an electromagnetic force.**
Bending magnet a **Synchrotron Radiation Sources**
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- Undulator & Wiggler
wiggler are periodic array of magnetic poles providing
petic field on axis for the production of synchrotron radiation **Undulator & Wiggler**
• Undulator and wiggler are periodic array of magnetic poles providing an
• The wiggler and undulator are characterized by period length and the deflection
• The wiggler and undulator are characterize **Undulator & Wiggler**
Undulator and wiggler are periodic array of magnetic poles providing an
alternating magnetic field on axis for the production of synchrotron radiation.
The wiggler and undulator are characterized by p **Undulator & Wiggler
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alternating magnetic field on axis for the production of synchrotron radiation.
• The wiggler and undulator are characterized
-

Example: MAX IV 3 GeV ring

Example: MAX IV 3 GeV ring

Example: MAX IV 3 GeV ring

Bending Magnet:

0.523 Tesla Bending Field

Wiggler:

Period length: 50 mm

K-value: 9.0

Length: 2 m K-value: 9.0 $\frac{2}{\pi}$ notice. 5.0
Length: 2 m

$$
\left(\frac{1}{2}, \frac{1}{2}, \frac
$$

Undulator:

Beamlines @ MAX IV: A Portfolio

Flux, Brilliance & Coherence

List IDs @ MAX IV

*) Built by collaboration with SOLEIL synchrotron

*) Built by industry (In-vacuum Undulators)

*) Built in-house (APPLE II)

*) Transfer from MAX-II ring (characterized at MAX IV ID magnet lab)

Permanent Magnet Technolgy

Pure Permanent Magnet Technologies (Out-of-vacuum) for VUV-Soft X-ray Permanent Magnet Technology
Pure Permanent Magnet Technologies (Out-of-vacuum) for VUV-Soft X-ray
beamlines (4 – 2000 eV). Hybrid structure of magnet and iron pole is also
utilized. utilized.

Features:

In-vacuum Technology

- In-Vacuum Technology
• Short magnet period of an undulator is desired for experimental stations using hard X-
• The 'In-vacuum Undulator' (IVU) magnetic circuit could be made out of pure
permanent magnet or hybrid, i.e., M rays. The magnet arrays are installed inside the vacuum chamber.
- The 'In-vacuum Undulator' (IVU) magnetic circuit could be made out of pure permanent magnet or hybrid, i.e., Magnet & Iron pole.
- The operation of IVU could be at room temperature or at cryogenic temperature to gain more magnetic strength and stability.

At MAX IV, period lengths ranges from 15 mm to 19.3 mm with minimum magnetic gap around & 4 mm at ring's ID.

Magnet Technologies

More radiation sources:

- - Bending magnet.
	-

Magnet Te

More radiation sources:

1. Electromagnets:

• Bending magnet.

• Undulator & Wiggler.

More efficient for long period ID or fast polariza Magnet Technol

Pradiation sources:

Lectromagnets:

Lectromagnets:

Pending magnet.

Pending magnet.

More efficient for long period ID or fast polarization switching in he

undulators. Cooling limitation on magnetic fiel IVIDBITEL TECT

More radiation sources:

2. Electromagnets:

2. Bending magnet.

2. Bending Magnet based on permanent

2. Bending Magnet based on permanent

2. Bending Magnet based on permanent

2. Bending Magnet based on 3. Superconduction sources:

3. Electromagnets:

• Bending magnet.

• Undulator & Wiggler.

• More efficient for long period ID or fast polarization switching in h

• More fluction completion on magnetic field strength.
 Compact APPLE X @ MAX IV

More efficient for long period ID or fast polarization switching in helical undulators. Cooling limitation on magnetic field strength.

- magnets. 4. And more.

4. And more efficient for long period ID or fast polariza

4. And more.

4. And Mo
- -
	-
	- K value.
- -
	-
	-

Brilliance @ MAX IV Rings

Polarization

Polarization
• Beamline requirements for variable polarization,
elliptical and/or linear, is achievable by many magnetic
configurations, most commonly used the APPLE II **Polarization**
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Radiation pattern from an APPLE II undulator
Radiati Beamline requirements for variable polarization,
elliptical and/or linear, is achievable by many magnetic
configurations, most commonly used the APPLE II
configuration. It enables polarization switching too.
Radiation pat

Radiation pattern from an APPLE II undulator

 $\mathbf 0$

 Θ_{χ} [mrad]

 0.5

 -0.5

exist:

electromagnet.

Coherence

The small emittance of electron beam, the length of the undulator and the β function at
ID location enable better matching of the electron and photon phase spaces to enhances
significantly the transverse coherence of the **CONETENCE**
The small emittance of electron beam, the length of the undulator and the β function at
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significantly the transverse co **Significantly the transverse coherence of the photon beam from an ID.**
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Quasi-periodic Undulator

- **Quasi-periodic Undulator**
• The on-axis radiation power for the low photon energy beamlines creates heating
• The qauasi-periodic magnetic field is modified by introducing quasi-periodicity.
• The qauasi-periodic motion o
- **Quasi-periodic Undulator**
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problems. The periodic magnetic field is modified by introducing quasi-periodicity.
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• The qauasi-periodic motion

APPLE II Undulators - Spectra
PLE II undulators are the VUV-Soft X-ray sources at MAX IV with full
ation control.

- **APPLE II Undulators Spectra**
• The APPLE II undulators are the VUV-Soft X-ray sources at MAX IV with full
• Step and continuous scanning is available in gap-phase (energy-polarization) **APPLE II Undulators**
The APPLE II undulators are the VUV-Soft X-ray sc
polarization control.
Step and continuous scanning is available in gap-₁
space.
- **STEP APPLE II Undulators Spectra**

Step and continuous scanning is available in gap-phase (energy-polarization)

Step and continuous scanning is available in gap-phase (energy-polarization)

Space. space.

$\text{APPLE II } \lambda_{\text{u}} = 48 \text{ mm } \& \text{ L} = 4 \text{ m}$

The measured peak and side lobes features of the VERITAS spectrum are indistinguishable from the zero-emittance case. This precision is impossible with the much larger emittance of 3rd generation machines

$$
APPLE II \lambdau=53 mm & L=4 m
$$

- In-vacuum Undulators Spectra **in-Vacuum Undulators - Spectra**
• High brilliance, hard x-rays sources are based on room temprature and short
• The definition of undulators' parameters (gap & λ) has capitalized on the
delivered electron beam bunch lo
- **In-vacuum Undulators Spectra**
High brilliance, hard x-rays sources are based on room temprature and short
period In-vacuum undulators with hybrid magnetic structure.
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High brilliance, hard x-rays sources are based on room temprature
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The definition of undulators' parameters (gap & λ) has capi

Length 2 meters, Min. gap 4.2 mm

- Spectral width is negligibly broadened due
to small emittance.
Digeopostic tool for accelerator to small emittance.
- Diagnostic tool for accelerator performance

DanMAX undulator, λ=16 mm, L=3m.

Wiggler @ MAX IV **Wiggler @ MAX IV**
• High flux wiggler (21 kW @ 500 mA, 3 GeV) contributes to emittance damping by 5%.
• Undulator-like spectrum due to low emittance. **Wiggler @ MAX IV**
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-
-

Undulator radiation structure from BALDER wiggler. (small emittance)

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• Undulator-like spectrum due to low emittance.
• Ripples on *l_o* at Balder at variable e-beam direction Wiggler @ MAX IV

-
-

Undulator radiation structure from BALDER wiggler. (small emittance)

Magnetic Field Measurements

- An ID consists of many magnets that require measurement for tuning to achieve the required magnet field quality as defined by both the accelerator physics constraints and **Magnetic Field Me**
An ID consists of many magnets that require measurem
required magnet field quality as defined by both the ac
the undulator brilliance & line width.
Magnetic measurement methods of point and integrate
te
- Magnetic measurement methods of point and integrated field of In/Out of vacuum, room temperature or cryogenic insertion devices.
- Hall probes and wire systems such as flip coil, stretched wire or pulsed wire techniques.

Hall Probe bench @ MAX IV

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Hall Probe bench @ MAX IV

Energy (keV)

Magnetic Field Measurements

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ID's Effect on Electron Beam

- **ID's Effect on Electron Beam**
• The integrated magnetic field seen in the electron beam trajectory must be minimized,
• An ID introduces focusing on the electron beam optics that needs compensation. It does
lead to reduct **ID's Effect on Electron Beam**
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otherwise the residual field induces an angular kick, i.e., an orbit distortion.
An ID introduces focusin • The integrated magnetic field seen in the electron beam trajectory must be minimized,

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• An ID introduces focusing on the electron
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Summary

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• Undulator and wiggler enhance the production of SR. The undulator produces narrow band series of harmonics whereas wiggler produces a **Summary**
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Bending magnet produces continuous spectrum
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The beamlines requirements vary in terms
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polarization, coherence, quasi-periodicity of harmonics, ...etc.
Permanent magnet and electromagnets are the main sources of magnetic
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Permanent magnet and electromagnets are
field for the production of radiation.
Insertion devices purturb the electror
linear/nonlinear op

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